## What is claimed is:

1. A method of fabricating an electrode of a plasma display panel using a photo peeling method, comprising the steps of:

forming a photo material layer on a substrate, the adhesive strength of the photo material layer decreases when exposed to light;

exposing the photo material layer to light in correspondence to a desire pattern;

forming an electrode material layer on the exposed photo material layer;

forming a peeling material layer on the electrode material layer, the peeling material layer has higher adhesive strength than an exposure area of the photo material layer; and

taking off the peeling material layer to pattern the electrode material layer.

- 2. The method according to claim 1, wherein the exposure area of the electrode material layer is removed when taking off the peeling material layer.
- 3. The method according to claim 1, further includes the step of:

firing the remaining area except where the electrode material layer is removed by the peeling material layer.

4. The method according to claim 1, wherein the photo material layer includes:

binder of 20~50 wt%; reactive monomer of 40~70 wt%; photo initiator of 2~5 wt%; and additive of 2~5 wt%.

- 5. The method according to claim 4, wherein the binder includes at least one of polyurethane, Polyester, polyacrylate, co-polymer with carboxylic -COOH and radical OH or tri-polymer with carboxylic -COOH and radical OH.
- 6. The method according to claim 4, wherein the reactive monomer includes at least one of a multi-functional monomer with 2~5 reactive radicals, acrylic monomer or urethane monomer and oligomer.
- 7. The method according to claim 4, wherein the photo initiator includes at least one of 1-hydroxy-cyclochexyl-phenyl ketone, p-pheny benzo phenone, benzyldimethylketal, 2,4-dimethylthioxanthone, 2,4-diethylthioxanthone, benzoin ethyl ether, benzoin isobutyl ether, 4,4'-diethylaminobenzophenone, p-dimethyl amino benzoic acid ethylester.
- 8. The method according to claim 5, wherein the additive includes at least one of dispersing agent, stabilizer and polymerization prohibiting agent.
- 9. The method according to claim 1, wherein the electrode material layer includes:

silver Ag powder of 90~99 wt%; and glass-frit of 1~10 wt%.

10. The method according to claim 1, wherein the peeling material layer includes:

binder of 70~80 wt%; and additive of 20~30 wt%.

- 11. The method according to claim 10, wherein the binder includes at least one of polyurethane, Polyester, polyacrylate, co-polymer with radical OH or tri-polymer with radical OH.
- 12. The method according to claim 10, wherein the additive includes at least one of dispersing agent, stabilizer or adhesive.